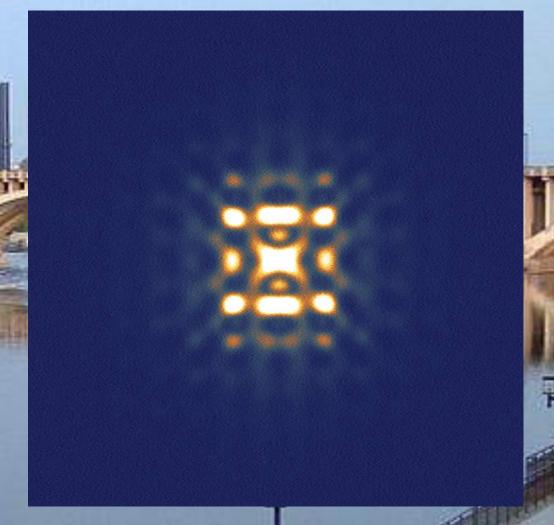


escription: **Experimental** measurement of the wavefunction of a single buried arsenic dopant atom peeking through a hydrogenterminated silicon surface.



Magnification (3"x4" image): 8467KX (12x12 nm)

Submitted by: Taleana Huff

Instrument: Omicron LT-SPM **Affiliation: University of Alberta**

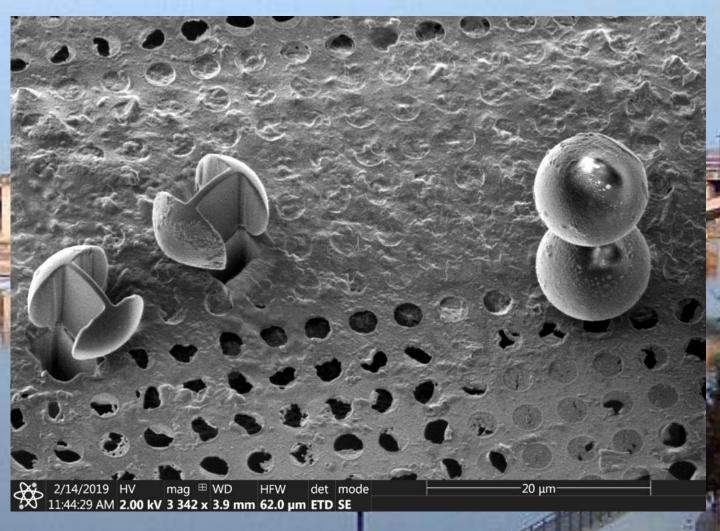


2

Micrograph Title: Imperial TIE fighters attacking an innocent Minnesotan micro-snowman

Description:

Lamellas were ionmilled in fluorescent polysterene spheres



Magnification: 3.3KX (3"x4" image)

Submitted by: Sergey Gorelick

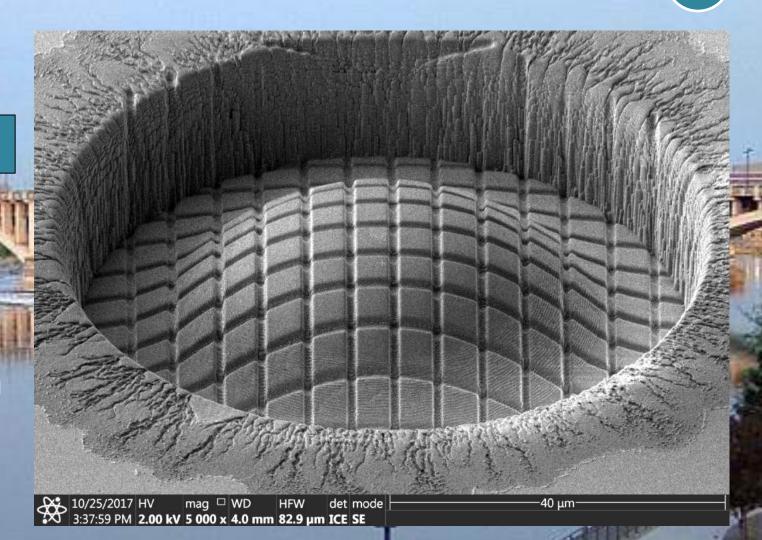
Instrument: ThermoFisher Helios Ux-G4
Affiliation: Monash University, Australia

Micrograph Title: Micro-Mango

Harman Har

Description:

Microlens milled in glass with a focused Xe beam. A 2D grating was then etched into its surface



Magnification: 5KX (3"x4" image)

Submitted by: Sergey Gorelick

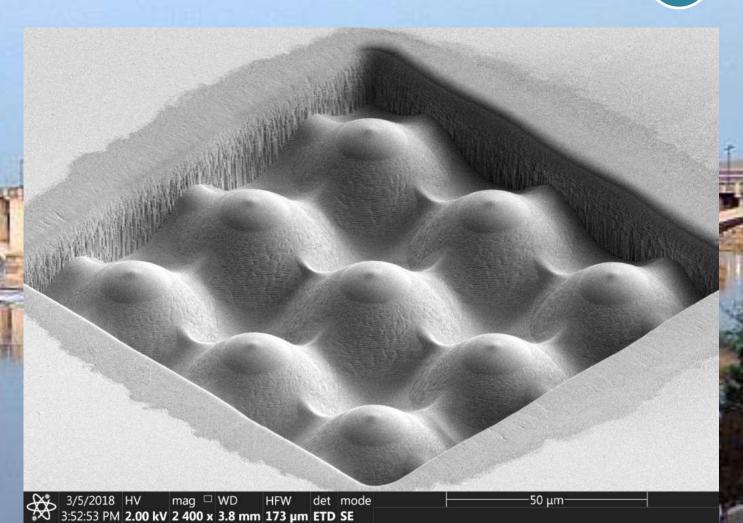
Instrument :ThermoFisher Helios Ux-G4

Affiliation: Monash University, Australia

Micrograph Title: Little brother is watching you

Description:

An array of microlenses milled in glass using a focused Xe beam



Magnification: 2.4KX (3"x4" image)

Submitted by: Sergey Gorelick

Instrument: ThermoFisher Helios Ux-G4
Affiliation: Monash University, Australia



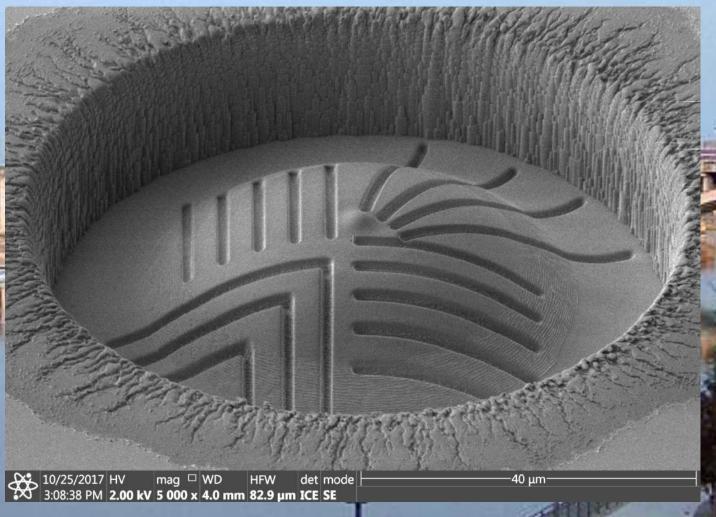


Micrograph Title: Micro mumbo jumbo

THE PERSON NAMED IN COLUMN TWO IS NOT THE OWNER.

Description:

Microlens milled in glass with a focused Xe beam. Surface features were then etched into its surface



Magnification: 5KX (3"x4" image) Instrument: ThermoFisher Helios Ux-G4

Submitted by: Sergey Gorelick Affiliation: Monash University, Australia



Description:

Concentric rings with variable depth were milled in Si using a focused Xe beam



10/10/2017 HV mag [⊞] WD HFW det mode 5:15:56 PM **5.00 kV 2 000 x 4.0 mm 104 μm ETD SE**

-50 µm

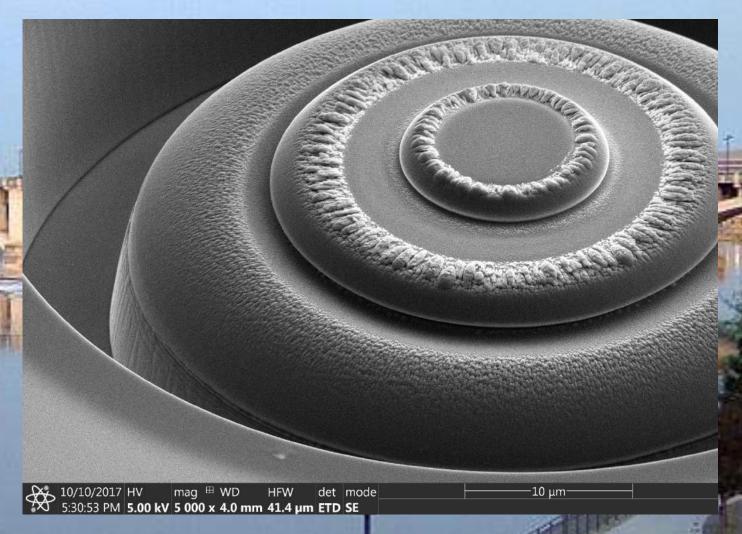
Magnification: 5KX (3"x4" image) Instrument :ThermoFisher Helios Ux-G4
Submitted by: Sergey Gorelick Affiliation: Monash University, Australia



Micrograph Title:
A delicious
chocolate Si layered
micro-cake with
extra topping

Description:

Concentric rings with variable depth were milled in Si using a focused Xe beam



Magnification: 5KX (3"x4" image) Instrument: ThermoFisher Helios Ux-G4

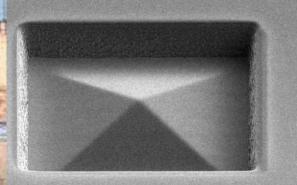
Submitted by: Sergey Gorelick Affiliation: Monash University, Australia

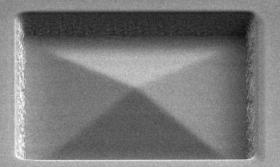






Pyramids were milled in lithium niobate crystal using a focused Xe beam





5/18/2018 HV mag [⊞] WD HFW det mod 10:48:45 AM **2.00 kV 1 200 x 4.0 mm 173 μm ETD SE**

Magnification: 1.2KX (3"x4" image)

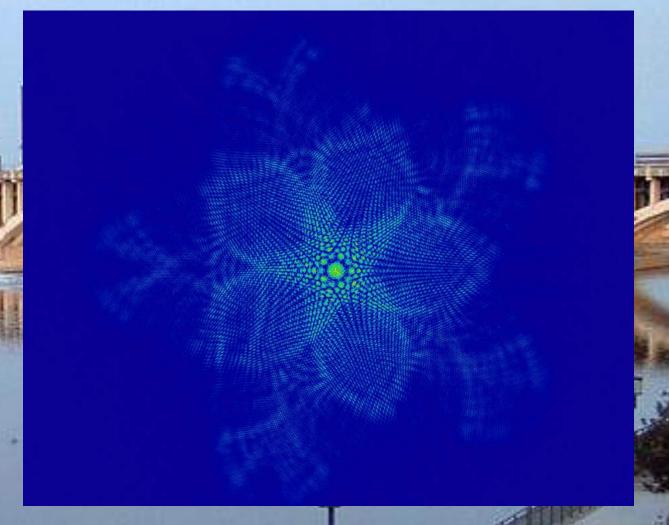
Submitted by: Sergey Gorelick

Instrument: ThermoFisher Helios Ux-G4
Affiliation: Monash University, Australia





Description:
Far-field intensity
produced by a
diffractive optical
element



Magnification: 40 (3"x4" image) Instrument: Andor Zyla 4.2 cMOS

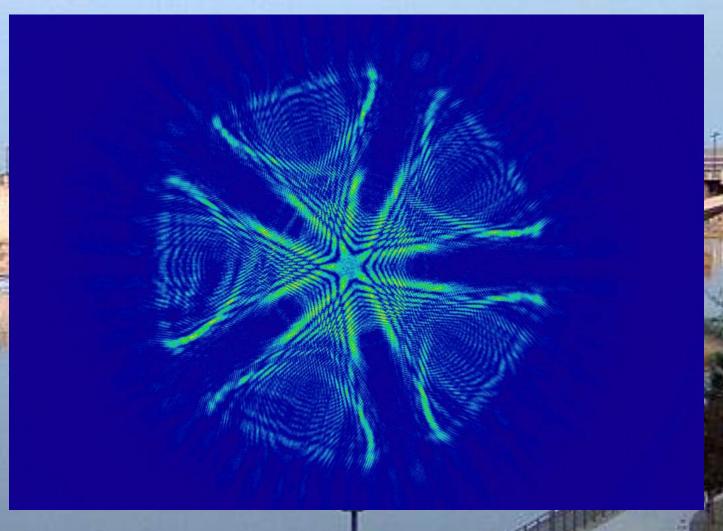
Submitted by: Sergey Gorelick Affiliation: Monash University, Australia

2019 EIPBN MicroGraph Contest





element



Magnification: 40 (3"x4" image) Instrument: Andor Zyla 4.2 cMOS

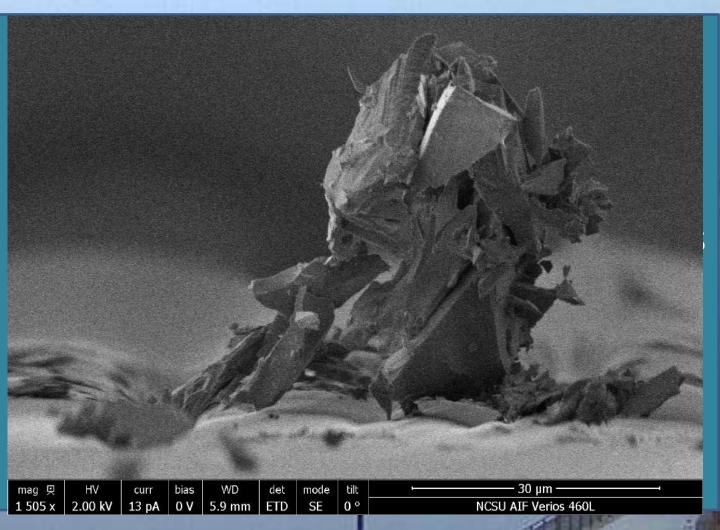
Submitted by: Sergey Gorelick Affiliation: Monash University, Australia

2019 EIPBN MicroGraph Contest



Transport of the

Description:
Where is Hydra! I'm going to kick his ass.



Magnification (3"x4" image): 1.5KX

Submitted by: Yi-An Chen

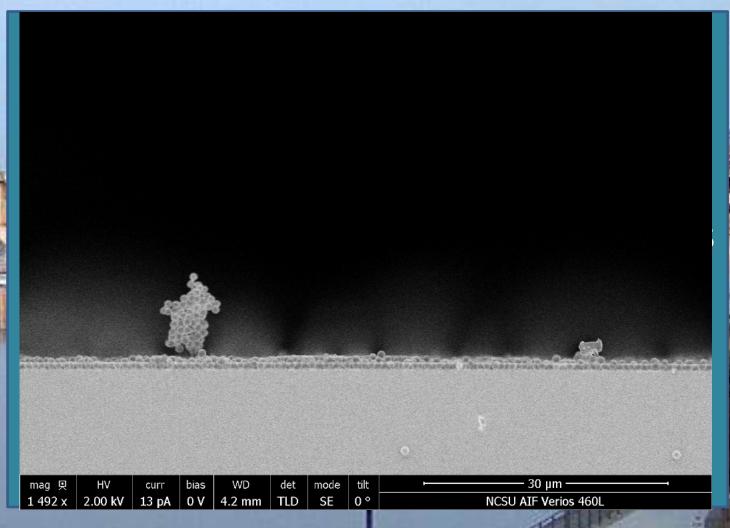
University

Instrument: FEI Verios 460L





Description: When you lose control of your puppy...



Magnification (3"x4" image): 1.5KX

Submitted by: Yi-An Chen

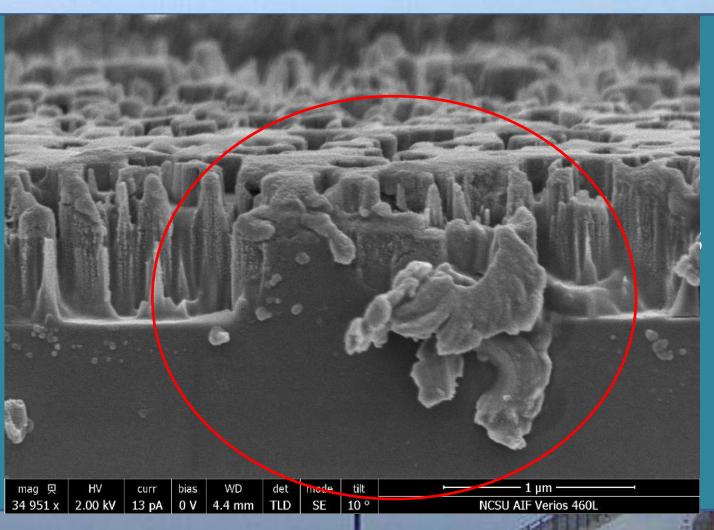
University

Instrument: FEI Verios 460L

2019 EIPBN MicroGraph Contest



Description: 10 dollar per person,



Magnification (3"x4" image): 2KX

Submitted by: Yi-An Chen

University

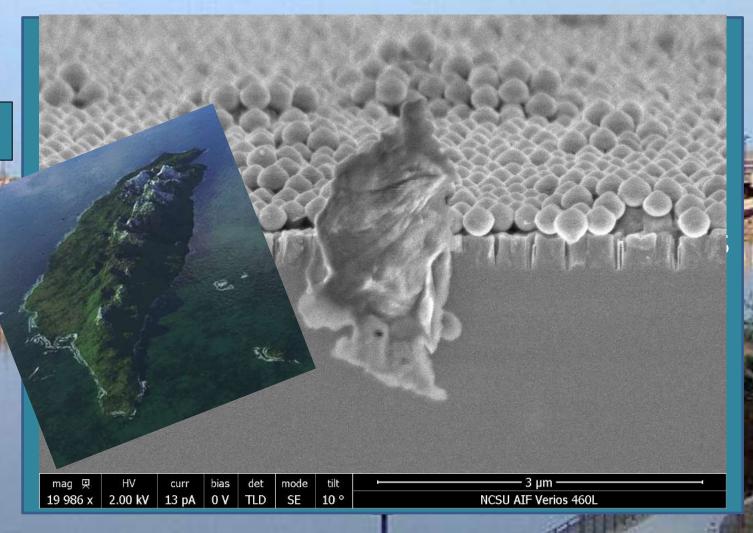
accept beer

Instrument: FEI Verios 460L

2019 EIPBN MicroGraph Contest



Description:
My island is like a
leaf at the edge of
Pacific ocean.



Magnification (3"x4" image): 2KX

Submitted by: Yi-An Chen

University

Instrument: FEI Verios 460L

2019 EIPBN MicroGraph Contest

Micrograph Title: Mini Mario (DO DO DO DaDo DO)

Description:

24 notes of the Super
Mario theme song
converted to binary and
stored in silicon
dangling bonds at a
density of 1.1 petabits
per square inch

Magnification: 21.5 nm x 10.7 nm

Submitted by: Roshan Achal

Instrument: Omicron LT STM

Affiliation: University of Alberta





Description:

When you leave a gold coated Si wafer in a IKEA box.

curr tilt WD det HFW Instrument: Nova Nanolab 650 SEM

Magnification (3"x4" image): 300X

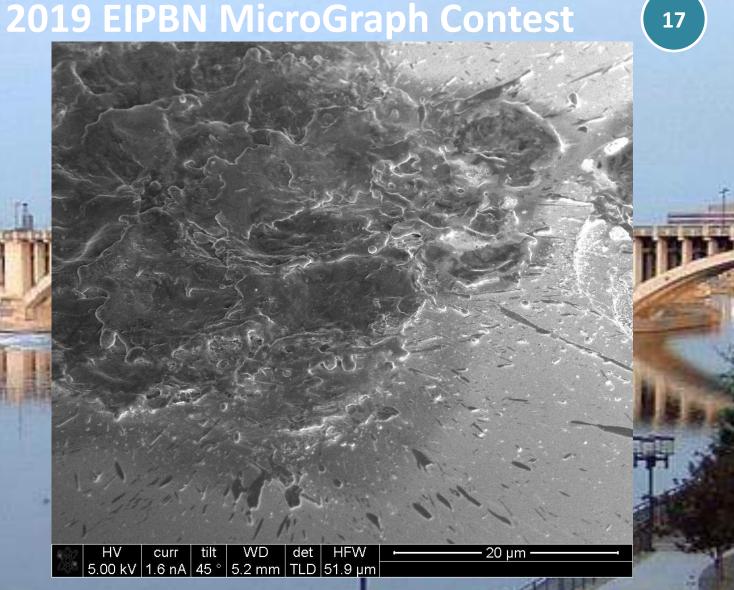
Submitted by: Gaudhaman Jeevanandam Affiliation: TU Delft, The Netherlands



Micrograph Title: A stormy day at the bay.

Description:

Results of arcing from a microplasma source on an Au film.



Nova Nanolab 650 SEM Magnification (3"x4" image): 2KX Instrument:

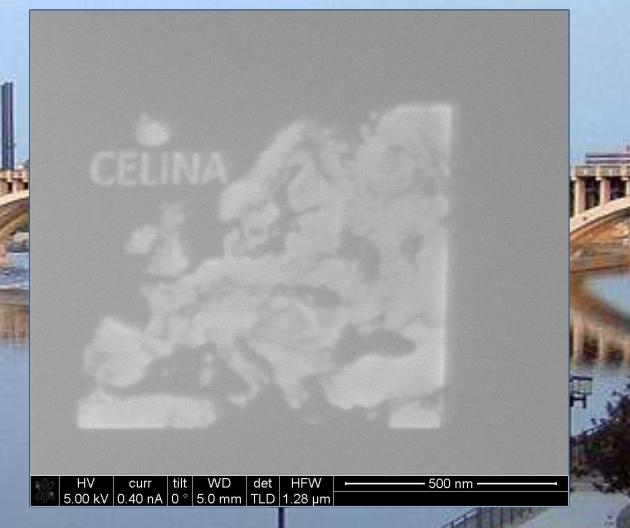
Submitted by: Gaudhaman Jeevanandam Affiliation: **TU Delft, The Netherlands**





Description:

Europe map
patterned using
Electron beam
induced deposition of
Platinum. This is in
3D, the heights differ
according to
altitudes!



Magnification (3"x4" image): 100KX Instrument: Nova Nanolab 650 SEM

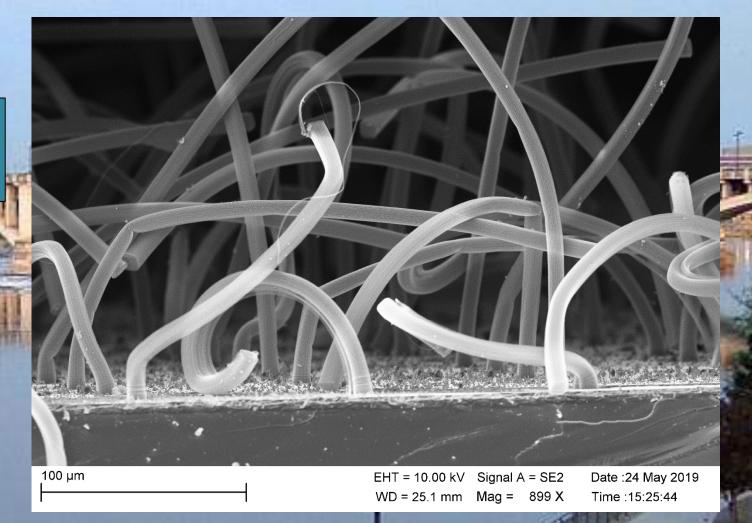
Submitted by: Gaudhaman Jeevanandam Affiliation: TU Delft, The Netherlands

2019 EIPBN MicroGraph Contest

Micrograph Title: Conference meeting of the car dealership inflatable tube men.

Description:

Array of 10 µm square pillars of multi-wall carbon nanotubes made by patterning array of iron catalyst islands on Si wafer.



Magnification (3"x4" image): 899X

Submitted by: Casimir Kuzyk

Instrument: Zeiss Sigma SEM

Affiliation: University of British Columbia

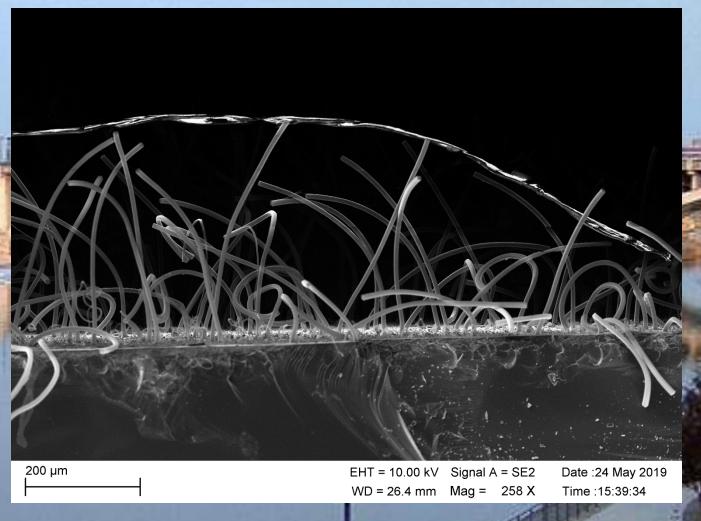






Description:

Array of 10 µm square pillars of multi-wall carbon nanotubes. Made by patterning iron catalyst islands on Si wafer. + somebodies hair



Magnification (3"x4" image): 258X

Submitted by: Casimir Kuzyk

Instrument: Zeiss Sigma SEM

Affiliation: University of British Columbia

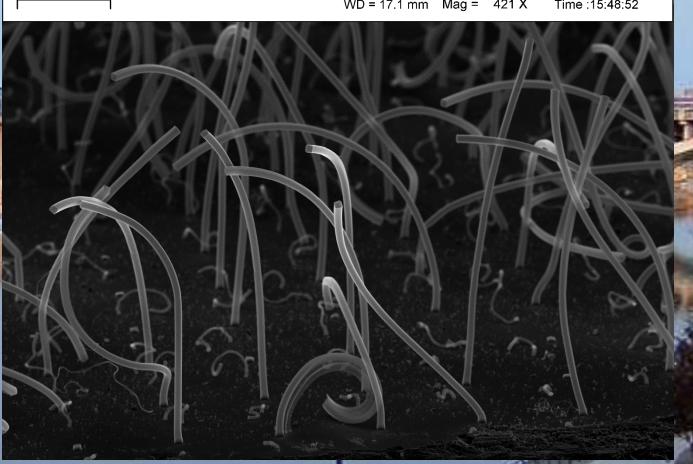
2019 EIPBN MicroGraph Contest

100 μm EHT = 10.00 kV Signal A = SE2 Date :24 May 2019
WD = 17.1 mm Mag = 421 X Time :15:48:52

Micrograph Title: Hair of the dog

Description:

Array of 10 µm square pillars of multi-wall carbon nanotubes. Made by patterning iron catalyst islands on Si wafer.



Magnification (3"x4" image): 421X

Submitted by: Casimir Kuzyk

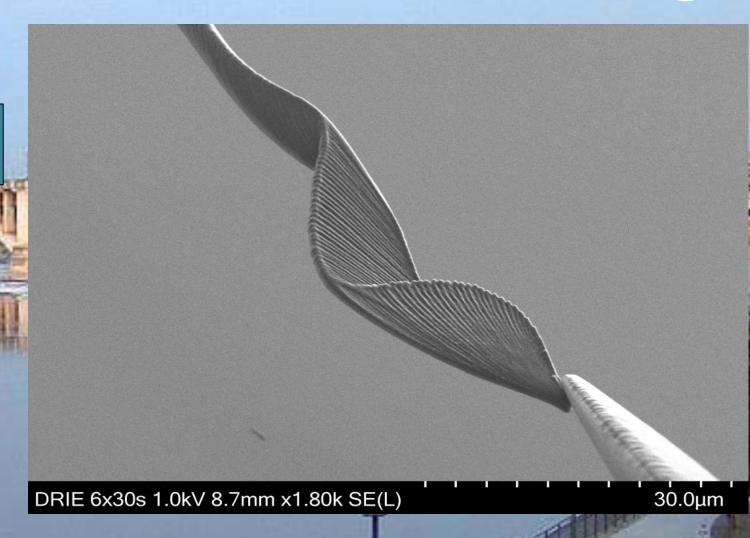
Instrument: Zeiss Sigma SEM

Affiliation: University of British Columbia



Description:

Unknown vibration disturbed the waveguide writing by Nanoscribe 3D, and was recorded in the resist.



Magnification (3"x4" image): 1.8KX

Submitted by: Jiangdong Deng (JD)

Instrument: Hitachi 8230 SEM

Affiliation: CNS at Harvard University

Micrograph Title: Ostrich wandering under the electron beam

Description:

Polymer particle under SEM

2.0kV 10.5mm x2.00k LM(UL) 07/09/2018

20.0μm

Magnification (3"x4" image): 2.0 KX

Submitted by: Jiangdong Deng (JD)

Instrument: Hitachi 8230 SEM

Affiliation: CNS at Harvard University





printer

CNS 4.0kV 20.3mm x2.50k SE(L) 01/16/2019 20.0µm

Magnification (3"x4" image): 2.5 KX

Submitted by: Jiangdong Deng (JD)

Instrument: Hitachi 8230 SEM

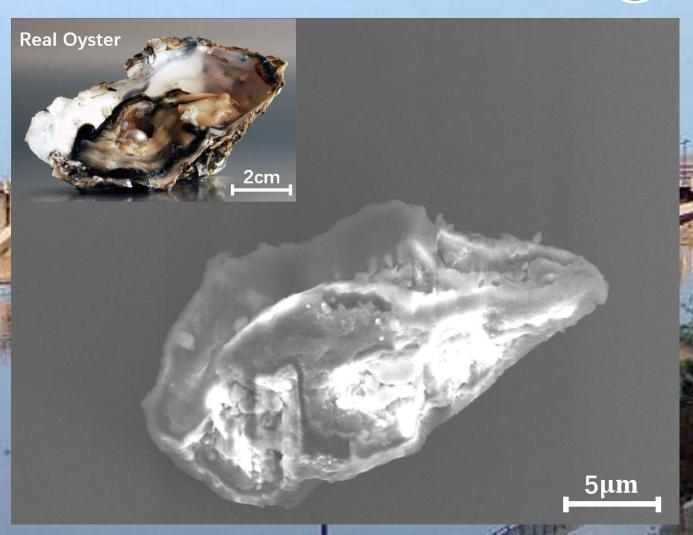
Affiliation: CNS at Harvard University







in this world!



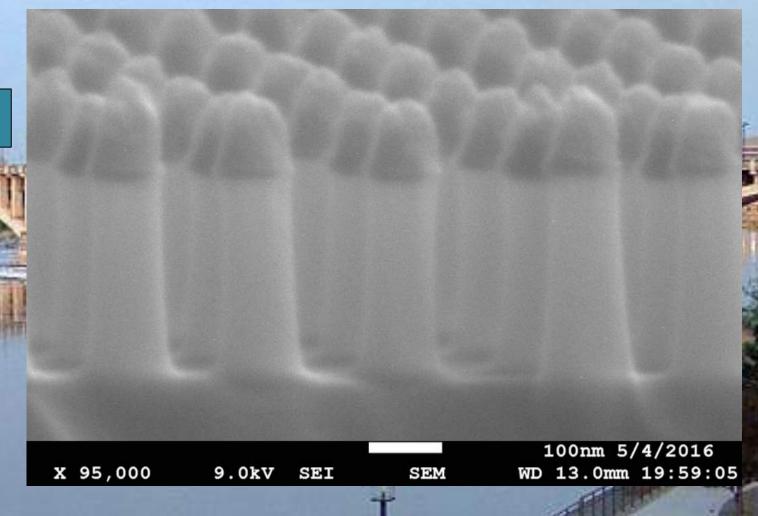
Magnification (3"x4" image): 2.3KX Submitted by: Hao Yang

Instrument: JEOL JSM-7001 - SEM Affiliation: University of Southern California



Description:
Array of nano

Array of nano pillars with gold cap. Made by nanoimprint lithography and reactive ion etching.



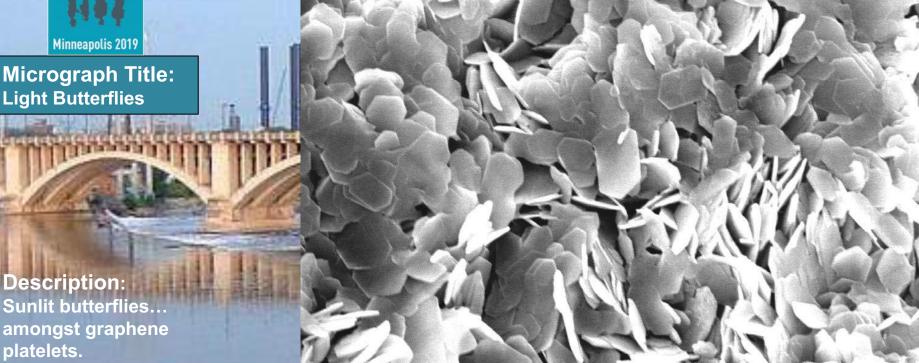
Magnification (3"x4" image): 95KX In

Submitted by: Boxiang Song

Instrument: JEOL JSM 7001

Affiliation: Univ. of Southern California





Magnification (3"x4" image): 5KX Submitted by: Jessica M. Andriolo

Instrument: Hitachi S-4700

Affiliation: Montana Technological

University

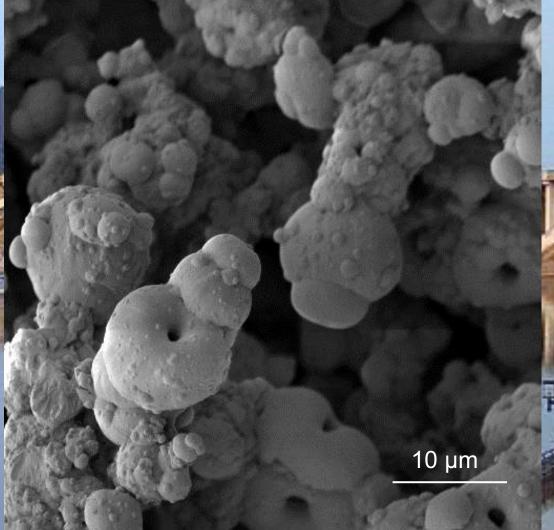
5 µm



Micrograph Title: Find the Lorax... eating a donut.

Description:

Hungry Lorax eating donuts in an electrosprayed mat.



Magnification (3"x4" image): 1KX Submitted by: Jessica M. Andriolo

Instrument: Tescan Mira 3

Affiliation: Montana Technological

University



Micrograph Title: Cratered Space Landmark

Description:

Electrosprayed landmarks found during planet exploration.

Instrument: Affiliation:

Magnification (3"x4" image): 1KX Submitted by: Jessica M. Andriolo **Tescan Mira 3**

Montana Technological

University

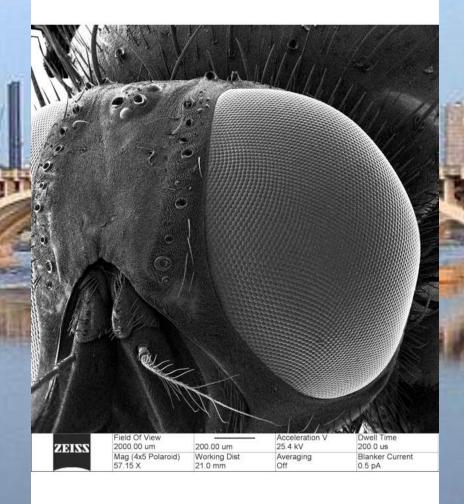
10 μm

2019 EIPBN MicroGraph Contest

Invader from outer space

Made using the Helium ion microscope. The fine detail and depth of focus are the special feature. A fly's eye.

THE STATE OF THE

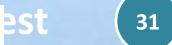


Magnification (3"x4" image): 57X

Submitted by: Mark Mondol

Instrument: Zeiss He ion microscope

Affiliation: MIT





Sapphire sphere

Field Of View Acceleration V 34.9 kV Dwell Time ZEISS 95.00 um 10.0 us 10.00 um

Mag (4x5 Polaroid) 1,203.16 X

Working Dist 14.5 mm

Detector PrimaryETDetector

Blanker Current

Magnification (3"x4" image): 1.2KX

Submitted by: Mark Mondol

Instrument:

Zeis He Ion microscope

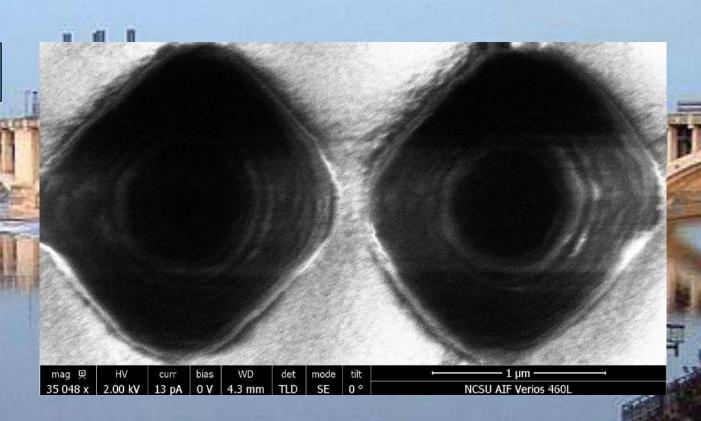
Affiliation:





THE RESERVE OF THE PARTY OF THE

Description: The SU8 pattern.

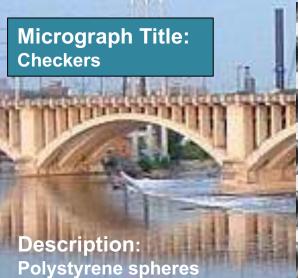


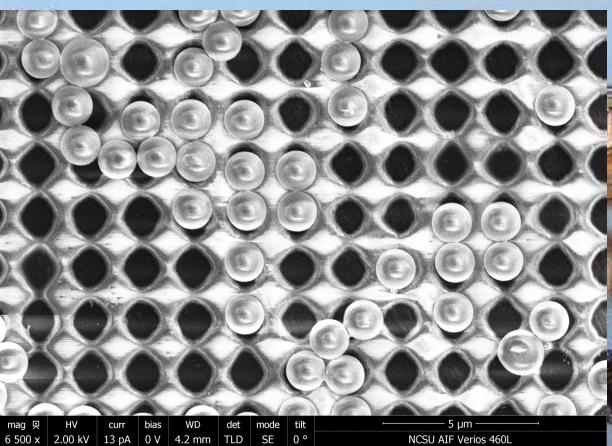
Magnification (3"x4" image): 2 KX

Submitted by: Zhiren Luo

University

Instrument: FEI Verios 460





Magnification (3"x4" image): 2 KX

Submitted by: Zhiren Luo

Affiliation:

Instrument:

North Carolina State

FEI Verios 460

University

on the photoresist

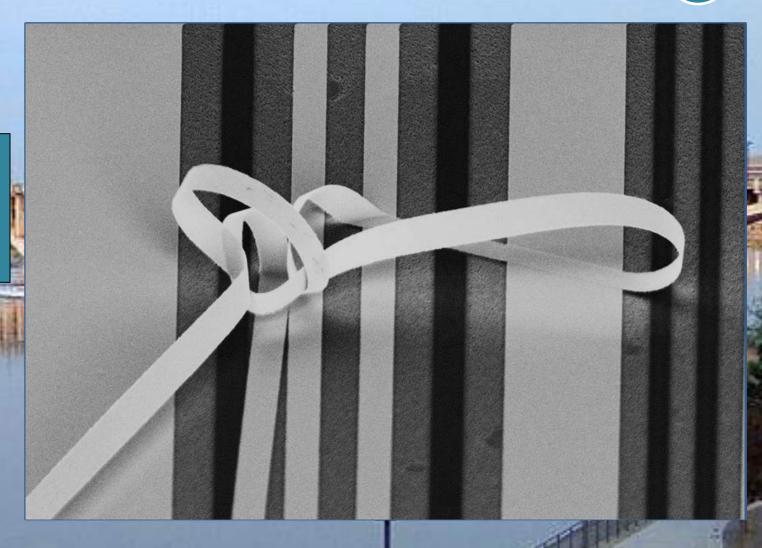
pattern.

Micrograph Title:

Ribbons for micron scale presents

Description:

Poor adhesion during pattern transfer of metallic nanometer-thick features actually can give ideas for next Xmas?



Magnification (3"x4" image): 10KX Submitted by: Gemma Rius

Instrument: LEO 1530 Zeiss

Affiliation: IMB-CNM-CSIC (Spain)

2019 EIPBN MicroGraph Contest

Micrograph Title:

Semiconductor **Dunes**

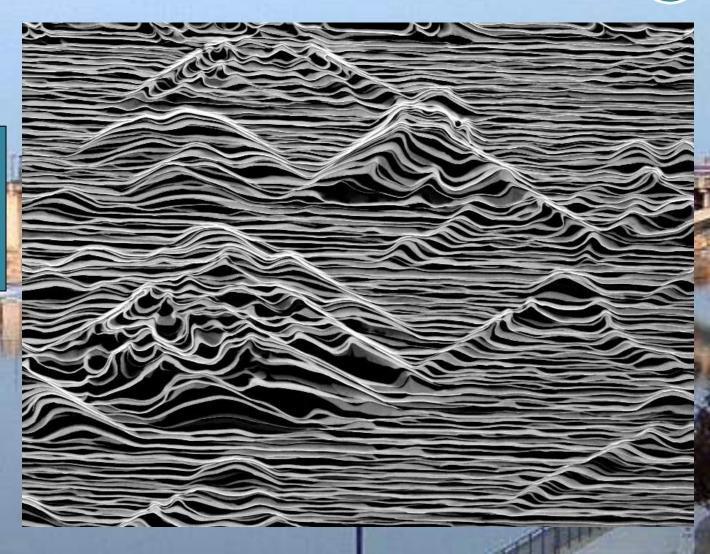
Description:
High temperature
treatment of
semiconductor is
always risky, yet it
can provide
beautiful
landscapes of a
micrometer world

Magnification (3"x4" image): 25KX

Submitted by: Gemma Rius

Instrument: LEO 1530 Zeiss

Affiliation: IMB-CNM-CSIC (Spain)





Micrograph Title: Falling elements

Description:
Our new method for micro/nano pattern transfer tryes defying our understanding of their adhesion, with the predominance of a gravity phenomenon!



Magnification (3"x4" image): 2KX Submitted by: Gemma Rius

Instrument: LEO 1530 Zeiss

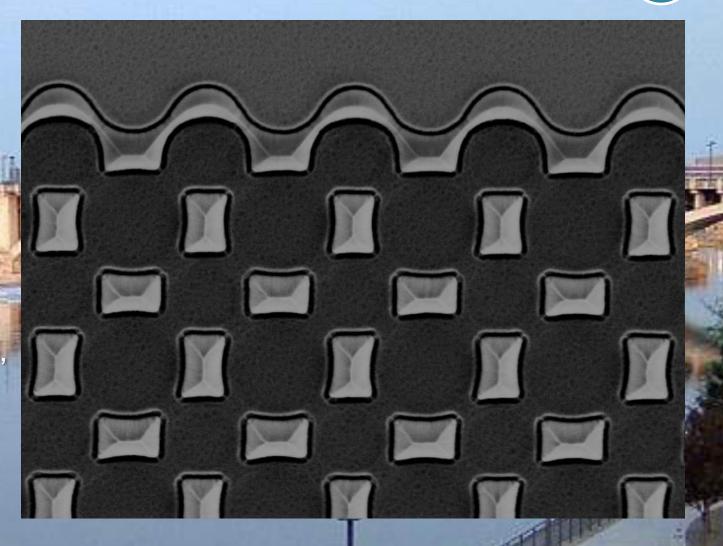
Affiliation: IMB-CNM-CSIC (Spain)



Micrograph Title:

Gaudi at the microscale

Description:
Gaudi-style curves
are very well known,
at the macroscopic
scale, but we
catalans have
challenged to
reproduce them
really small!



Magnification (3"x4" image): 10K

Submitted by: Gemma Rius

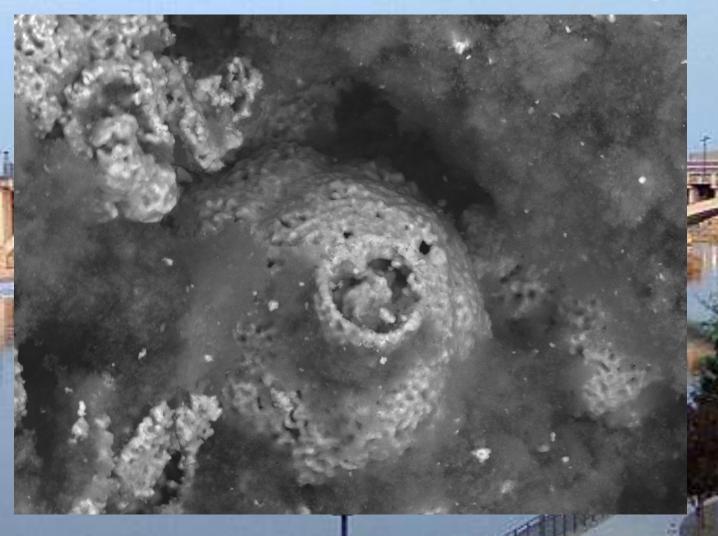
Instrument: LEO 1530 Zeiss

Affiliation: IMB-CNM-CSIC (Spain)

2019 EIPBN MicroGraph Contest

Micrograph Title: Screaming Eel

Description
Mn₃O₄ eel hiding
in the
carbonaceous
cave of a
composite
electrode.



Magnification (3"x4" image): 3.51 KX Submitted by: Molly Brockway

Instrument: Tescan Mira3

Affiliation: Montana Technological U.

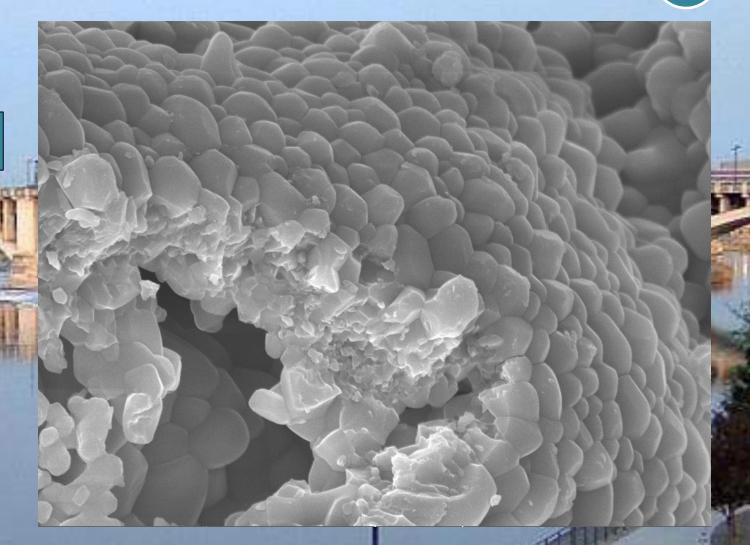
Butte, MT



Micrograph Title: Geode cave

Description:

The highly crystalline cave of a Mn₃O₄ hollow structure.
Adventurers beware!



Magnification (3"x4" image): 18 KX Submitted by: Molly Brockway

Instrument: Tescan Mira3

Affiliation: Montana Technological U.

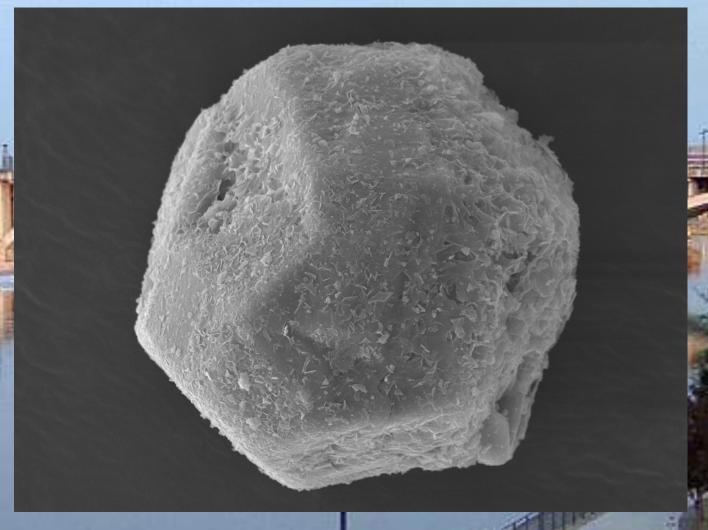
Butte, MT





Micrograph Title:
If Gnats Played
Dungeons and
Dragons This Would
Be Useful

Description:
What is this, a game for ants?? This 20-micron d12 is made for the tiniest barbarian that ever rolled a hit die. Assynthesized MnS crystallite.



Magnification (3"x4" image): 8.5 KX

Submitted by: Molly Brockway

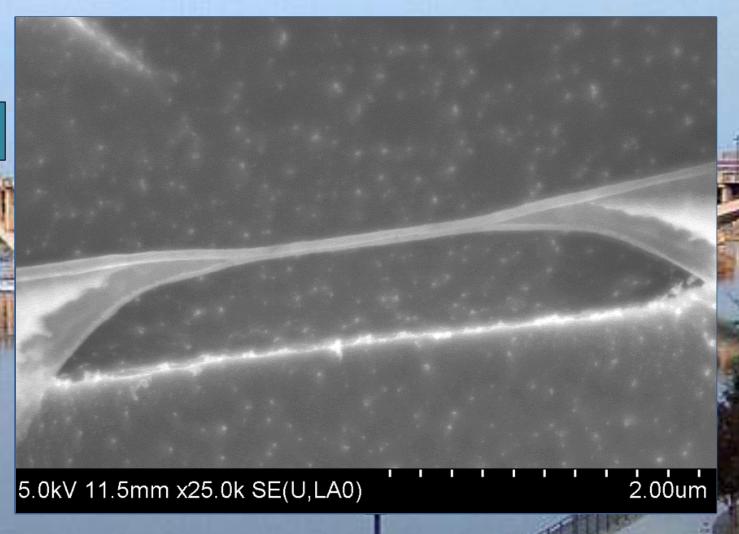
Instrument: Target SEM - 101

Affiliation: Montana Technological U.

Butte, MT

Micrograph Title: Nano-bridge

Description:
During ICP-RIE Si
etching, undercut
formed while using
PMMA + Alumina
hybrid resist mask
lead to suspended
bridge nanostructure



Magnification: 25KX

Submitted by: Nikhil Tiwale

Instrument : Hitachi 4800 SEM

Affiliation: Brookhaven National Laboratory

Upton NY, USA



Micrograph Title: Horror at Nanoscale

Description:
Due to the undercut
formation, as a
consequence of high
SF₆ ratio, during ICPRIE Si etch, can lead to
lifting off resist mask
and leave eroded
etched structure

2.00um 5.0kV 11.5mm x20.0k SE(U,LA0)

Magnification: 20KX

Submitted by: Nikhil Tiwale

Instrument: Hitachi 4800 SEM

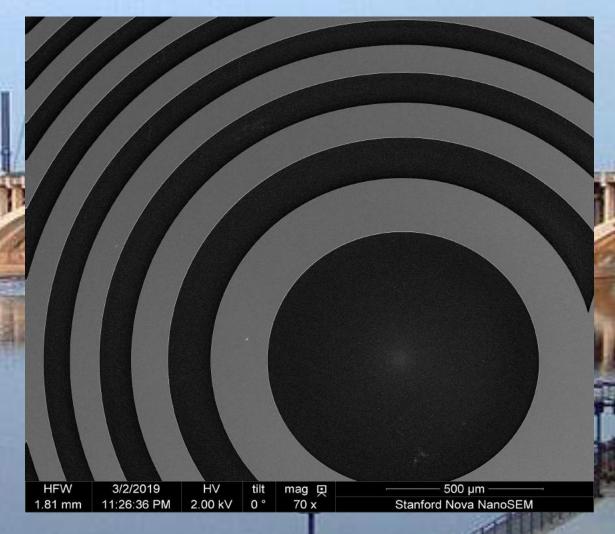
Affiliation: Brookhaven National Laboratory

Upton NY, USA



Micrograph Title: Shades of Grey

Description:
Black Silicon
fabricated by
Reactive-Ion Etching
in a Holographic
Fiducial Mark



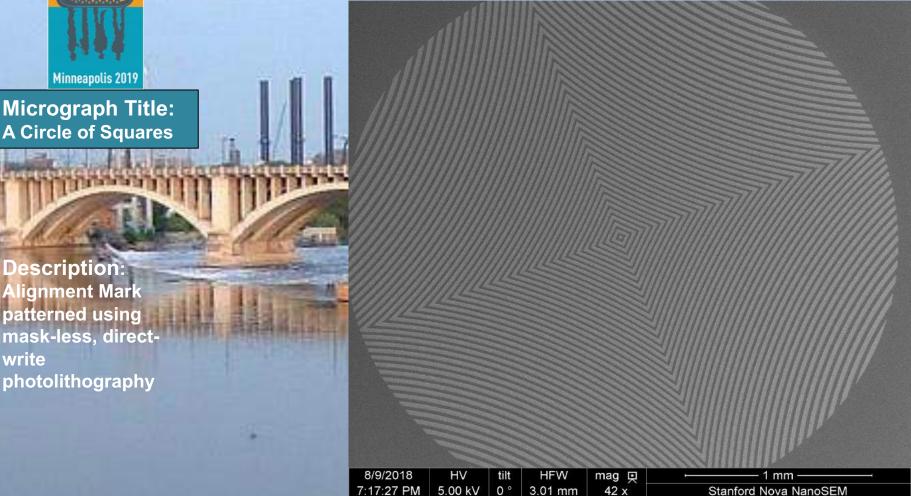
Magnification (3"x4" image): 70X

Submitted by: Maha Yusuf

Instrument: FEI Nova NanoSEM

2019 EIPBN MicroGraph Contest





Magnification (3"x4" image): 42X

Submitted by: Maha Yusuf

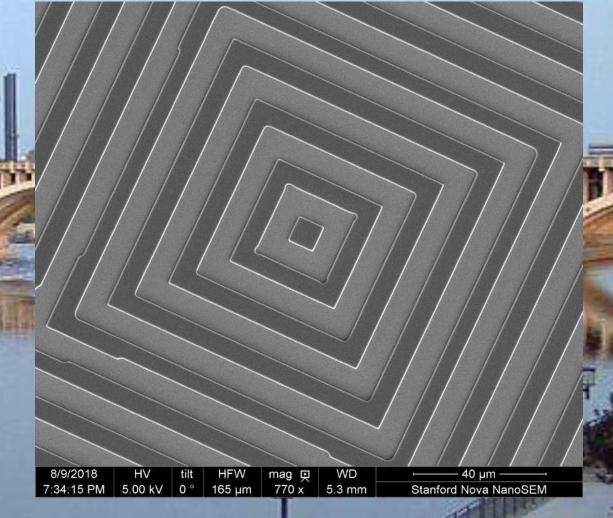
FEI Nova NanoSEM Instrument:

Stanford University, CA **Affiliation:**



Micrograph Title: Get lost in the Spain's largest Hedge Maze

Description:
Patterning of an alignment mark done using maskless, direct-write photolithography

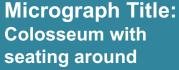


Magnification (3"x4" image): 770X

Submitted by: Maha Yusuf

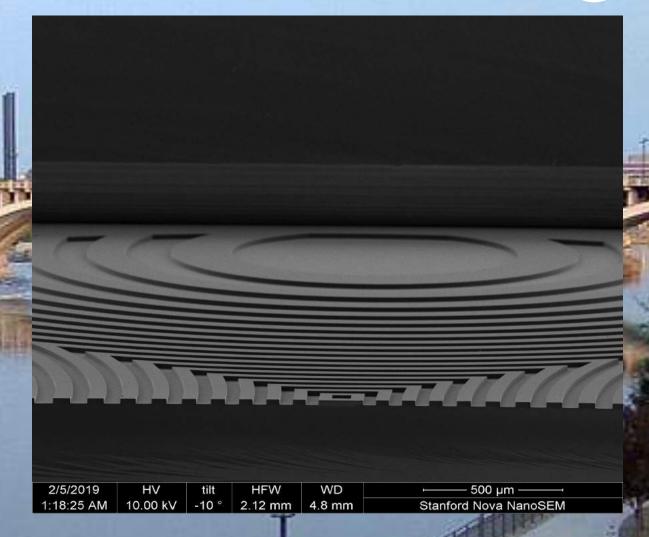
Instrument: FEI Nova NanoSEM





Description:

Tilted SEM image of the fabricated Holographic Fiducial Mark using Maskless Photolithography and Reactive-lon Etching



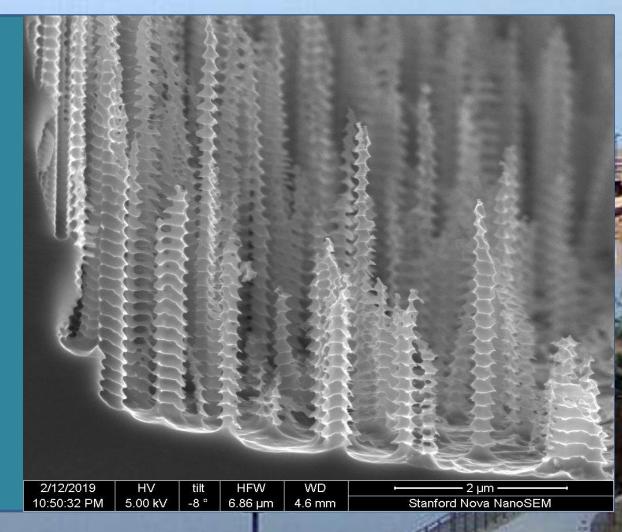
Horizontal Field Width: 2.12 mm

Submitted by: Maha Yusuf

Instrument: FEI Nova NanoSEM

Micrograph Title: Christmas Trees

Description:
Silicon MicroStructures
fabricated using
micro-masking in
the Reactive-lon
Etching process



Horizontal Field Width: 6.86 µm

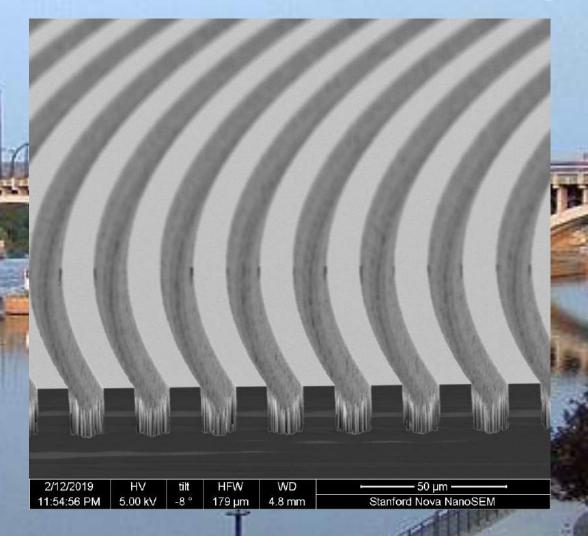
Submitted by: Maha Yusuf

Instrument: FEI Nova NanoSEM

2019 EIPBN MicroGraph Contest

Micrograph Title: Poisonous Snakes with needle-like fangs in their mouths

Description:
Zoomed in photo of
the etched VS
unetched regions of
the holographic
fiducial mark
fabricated using
Reactive-lon Etching
process



Horizontal Field Width: 179 μm

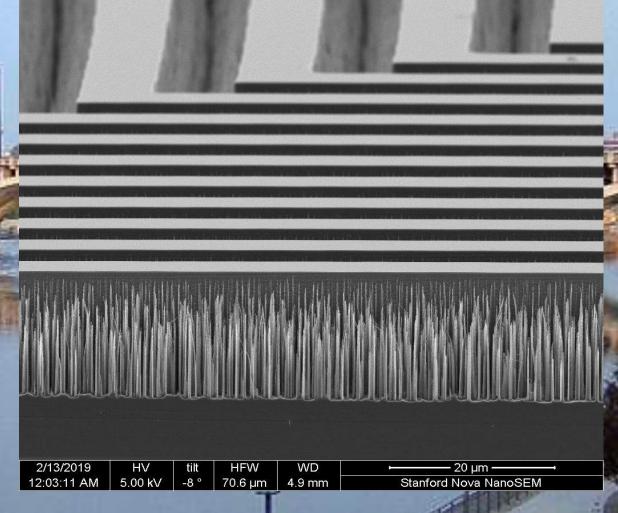
Submitted by: Maha Yusuf

Instrument: FEI Nova NanoSEM



Micrograph Title: Maze with thorns and thistles in between

Description:
Tilted CrossSectional SEM
image of an
Alignment Mark
containing silicon
structures in the
etched areas,
fabricated using
Reactive-Ion Etching
process



Horizontal Field Width: 70.6 μm

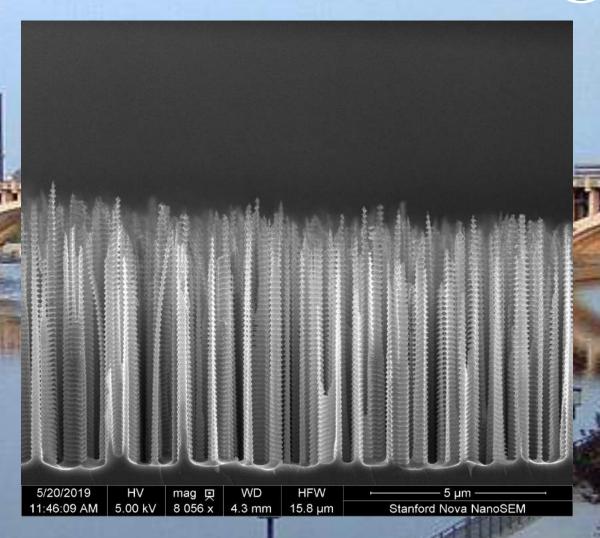
Submitted by: Maha Yusuf

Instrument: FEI Nova NanoSEM





Description:
Silicon MicroStructures
fabricated using
Reactive-Ion Etching
Process



Magnification (3"x4" image): 8056X

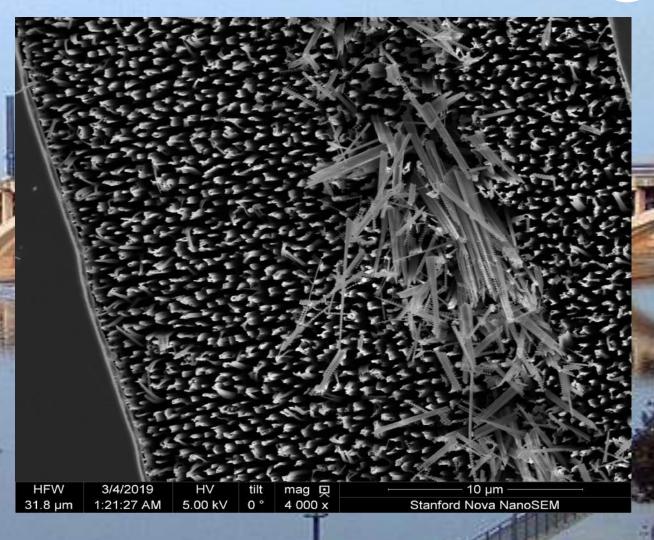
Submitted by: Maha Yusuf

Instrument: FEI Nova NanoSEM

2019 EIPBN MicroGraph Contest

Micrograph Title: Chaos in the middle of a battlefield

Description:
Broken Silicon
structures during
the silicon wafer
cleaving process



Horizontal Field Width: 31.8 µm

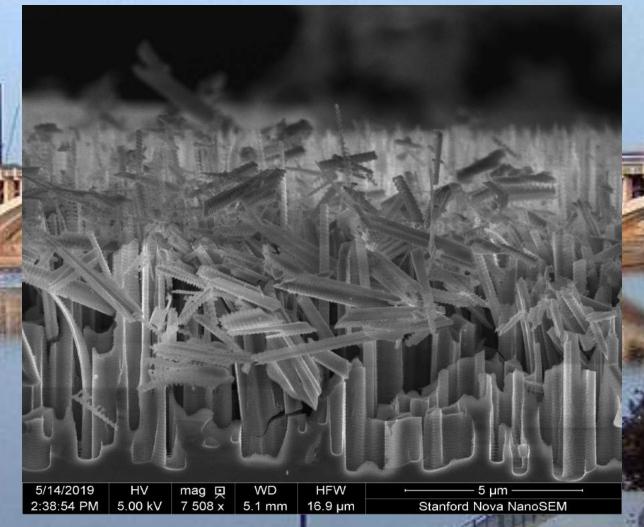
Submitted by: Maha Yusuf

Instrument: FEI Nova NanoSEM

2019 EIPBN MicroGraph Contest

Micrograph Title: Daenerys Targaryen destroying Kings Landing with her dragons

Description:
Broken Silicon
micro/nano
structures during
the Silicon wafer
cleaving process



Magnification (3"x4" image): 7508X

Submitted by: Maha Yusuf

Instrument: FEI Nova NanoSEM



Micrograph Title: When e-beam lithography goes wrong.

Description:
Copper / oxygen
dihydride core-shell
mm-scale nanotube
slightly over-etched
by naturallyoccurring high
energy beam of
electrons



Magnification (3"x4" image): 5X Submitted by: James Owen

Instrument : Affiliation:

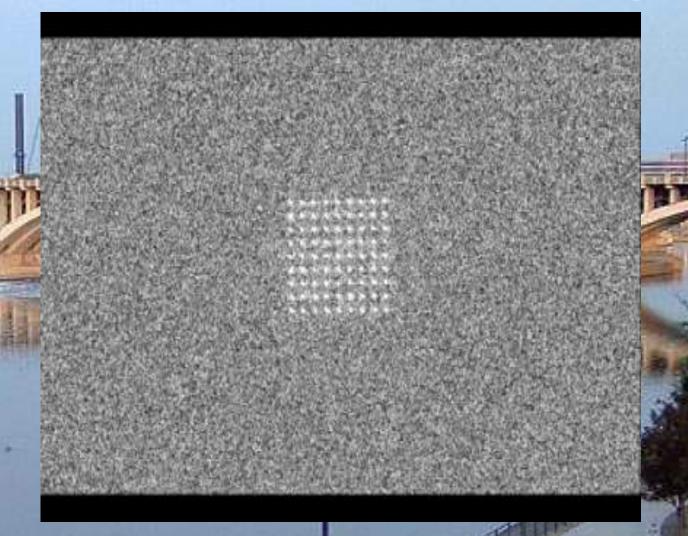
iPhone XS
Zyvex Labs
Thunderstorm Alley, TX



Micrograph Title: Minesweeper in SEM

Charles and the

When resist is on insulator, coating layer can't help much. Question: do these explosion really occur in the resist, is this a charging artifact, or did I just hit a mine?



Magnification (3"x4"): 40 um > HFW > 8 um Instrument : FEI - Helios NanoLab
Submitted by: Kerim Arat

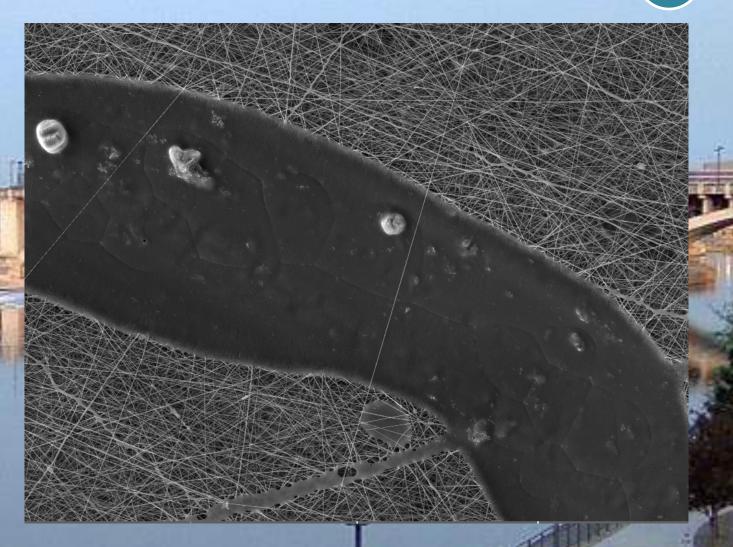
Affiliation: Delft University of
Technology



Micrograph Title: A River Runs Through It

Description:

A large river runs through a town filled with roads.



Magnification (3"x4" image): 1.5KX Submitted by: Lane Huston

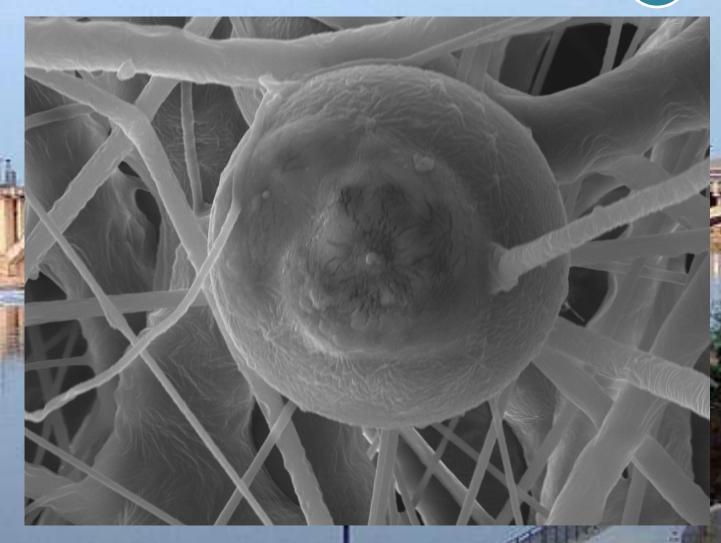
Instrument: Tescan MIRA3
Affiliation: Montana Technological Univ.

Butte, Montana

Micrograph Title: Titillating

Description:

We burned a hole into a polymer bead to make it look funny.



Magnification (3"x4" image): 5.89KX Submitted by: Lane Huston

Instrument: Tescan MIRA3

Affiliation: Montana Technological Univ.

Butte, Montana